

IONS ARE BYGONES

NEW CHALLENGES REQUIRE NEW SOLUTIONS

Today's semiconductor and microelectronics manufacturers face the challenge of the most complex cleaning application requirements. Berkshire has developed **Valuseal® IONX®**, a groundbreaking wiper with extremely low levels of releasable ions, to tackle this challenge.

Specifically created to offer long-term reliability and high yields, **Valuseal® IONX®** is the answer to the unique challenges of cleaning and maintaining cleanroom, production, and test equipment.

TECHNOLOGY	IONX®-An advanced proprietary ISO Class 4 cleanroom laundry process.
ADVANTAGES	<p>Ultra-low* levels of ionic extractables and leachables.</p> <p>Laser Sealed-Edge for reduced fiber separation and particle contamination.</p> <p>Lot Traceability</p>
RESULTS	<p>The highest level of contamination control in critical processing applications including ISO class 1-3 and higher cleanrooms.</p> <p>A chemically compatible match for IPA, Acetone, Ethanol, and other popular solvents or disinfecting solutions.</p>
INDUSTRIES	<p>Semiconductor</p> <p>Microelectronic</p>

VALUSEAL®
IONX®
ADVANCED WIPER TECHNOLOGY

BERKSHIRE.COM

SEE PRODUCTS

